## **Supporting Information for**

## High-Performance Photodetectors Based on MoTe<sub>2</sub>-MoS<sub>2</sub> van der Waals Heterostructures

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\* Corresponding to:

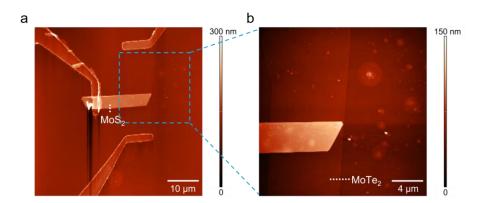
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**Figure S1.** AFM morphology image of the MoTe<sub>2</sub>-MoS<sub>2</sub> heterostructure.

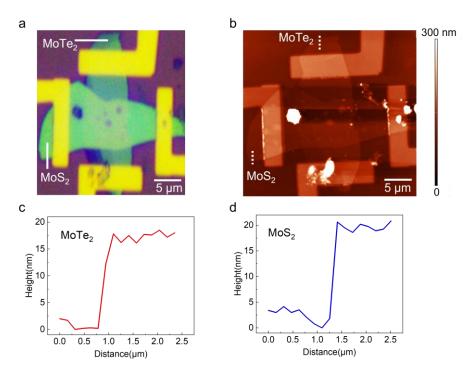
Figure S2. The characterizations of the MoTe<sub>2</sub>-MoS<sub>2</sub> heterostructures device.

**Figure S3.** The I-V curve of the MoTe<sub>2</sub>-MoS<sub>2</sub> heterostructures device before annealing.

Figure S4. Spatial distribution of the photocurrent.

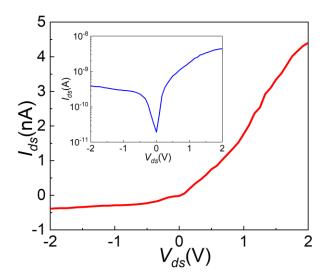


**Figure S1.** AFM morphology image of the MoTe<sub>2</sub>-MoS<sub>2</sub> heterostructure device in Figure 1c in the main text. (a) The AFM height image of device showing the height of MoS<sub>2</sub>. (b) The magnified AFM height image of device showing the height of MoTe<sub>2</sub>. The white dashed lines correspond to the height measurement of MoTe<sub>2</sub> and MoS<sub>2</sub>, respectively.



**Figure S2.** The characterizations of the MoTe<sub>2</sub>-MoS<sub>2</sub> heterostructures device. (a) The optical microscopy image of the device in Figure 1g-h and Figure 2e in the maintext. (b) The AFM height image of the device, and the white dashed line corresponds to the

height measurement of  $MoTe_2$  and  $MoS_2$ , respectively. (c) The height profile of  $MoTe_2$ , and the thickness of  $MoTe_2$  is about 16.7 nm. (d) The height profile of  $MoS_2$ , and the thickness of  $MoS_2$  is about 17.3 nm.



**Figure S3.** The *I–V* curve of the non-annealed MoTe<sub>2</sub>-MoS<sub>2</sub> heterostructures device. The inset picture shows the *I-V* characteristics in logarithmic coordinate.

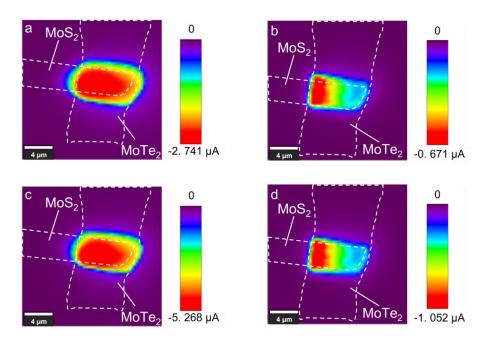


Figure S4. Spatial distribution of the photocurrent. (a)  $\lambda = 532$  nm,  $V_{ds} = -1$  V. (b)  $\lambda = 1064$  nm,  $V_{ds} = -1$  V. (c)  $\lambda = 532$  nm,  $V_{ds} = -2$  V. (d)  $\lambda = 1064$  nm,  $V_{ds} = -2$  V.